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(54) **NANOSTRUCTURED METAL OXIDES
COMPRISING INTERNAL VOIDS AND
METHODS OF USE THEREOF**

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(57) **ABSTRACT**

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The present invention relates to nano structures of metal oxides having a nanostructured shell (or wall), and an internal space or void. Nanostructures may be nanoparticles, nanorod/belts/arrays, nanotubes, nanodisks, nanoboxes, hollow nanospheres, and mesoporous structures, among other nanostructures. The nanostructures are composed of polycrystalline metal oxides such as SnO₂. The nanostructures may have concentric walls which surround the internal space of cavity. There may be two or more concentric shells or walls. The internal space may contain a core such ferric oxides or other materials which have functional properties. The invention also provides for a novel, inexpensive, high-yield method for mass production of hollow metal oxide nanostructures. The method may be template free or contain a template such as silica. The nanostructures prepared by the methods of the invention provide for improved cycling performance when tested using rechargeable lithium-ion batteries.

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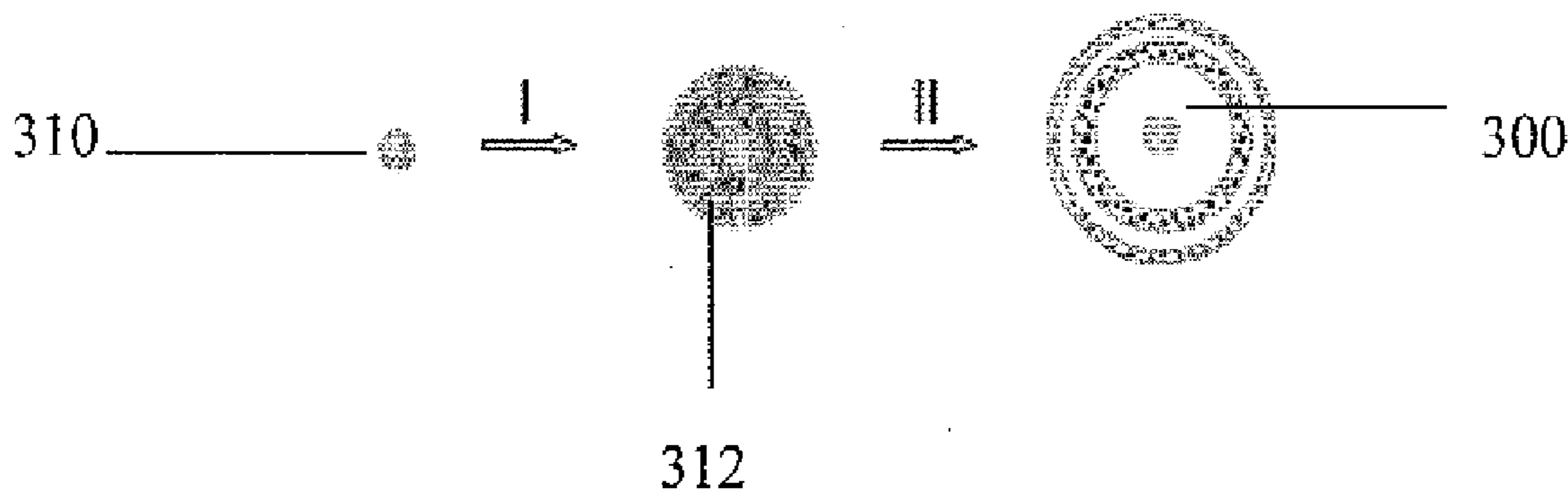


Figure 1A

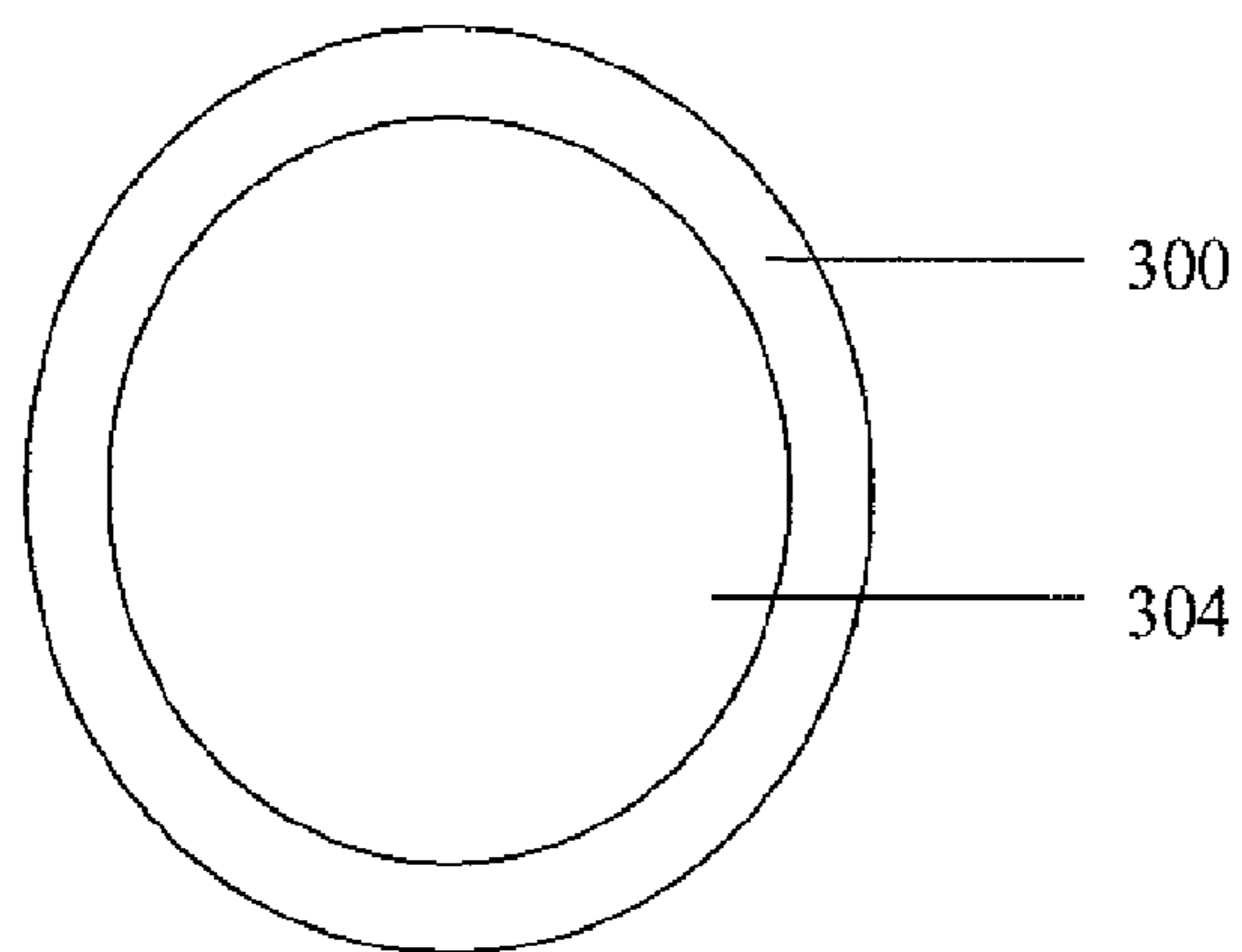


Figure 1B

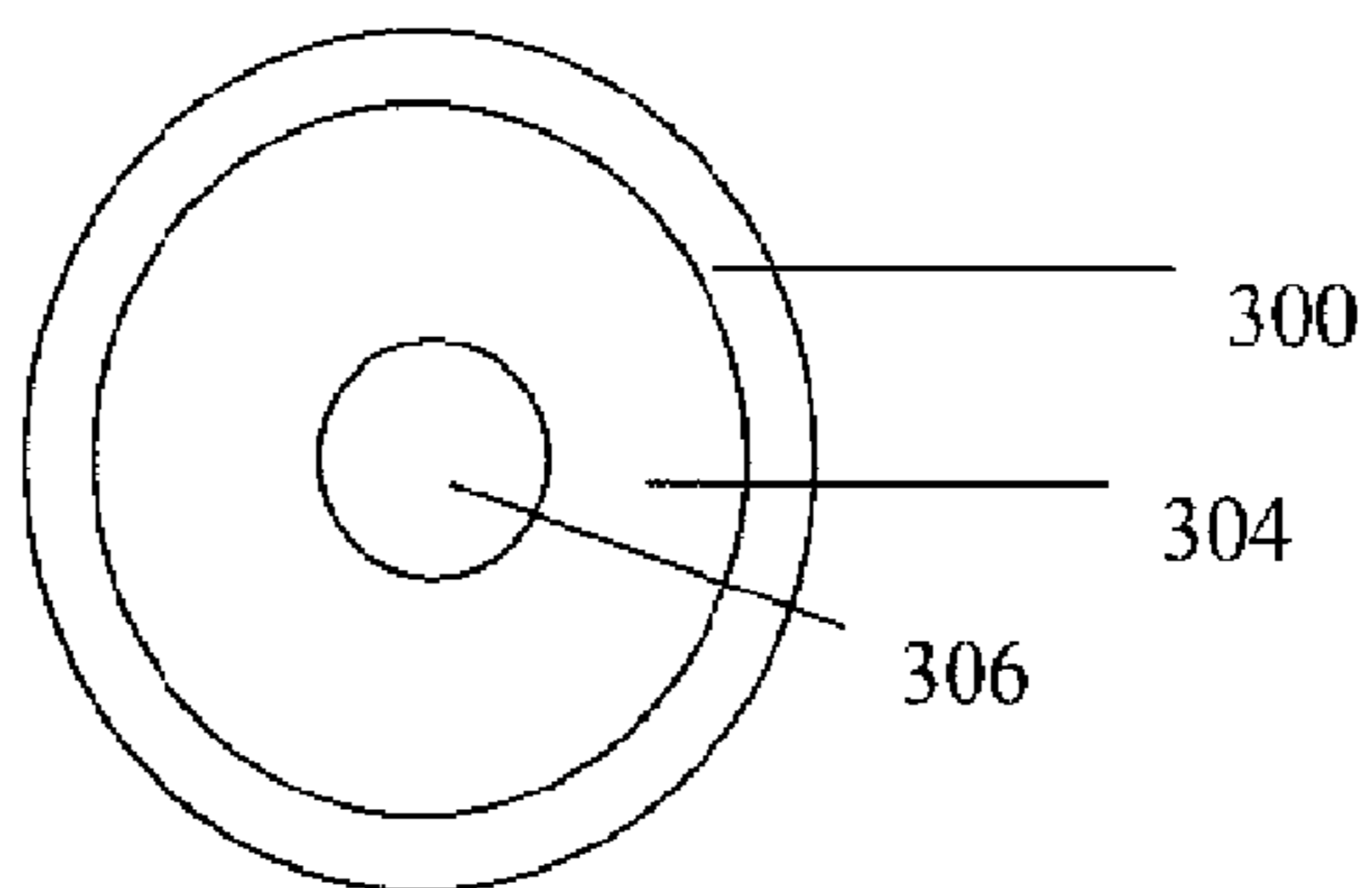


Figure 1C

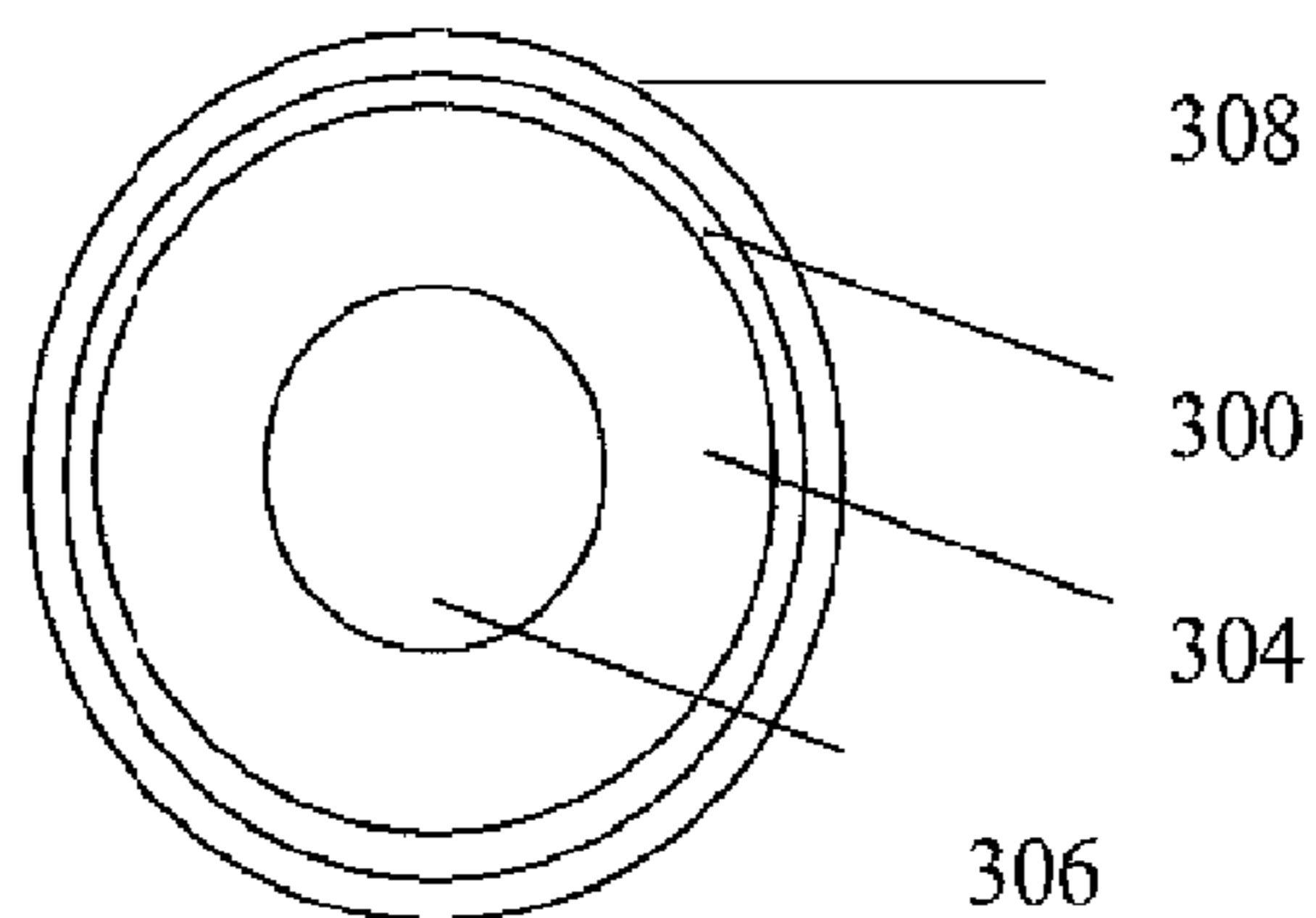


Figure 2A

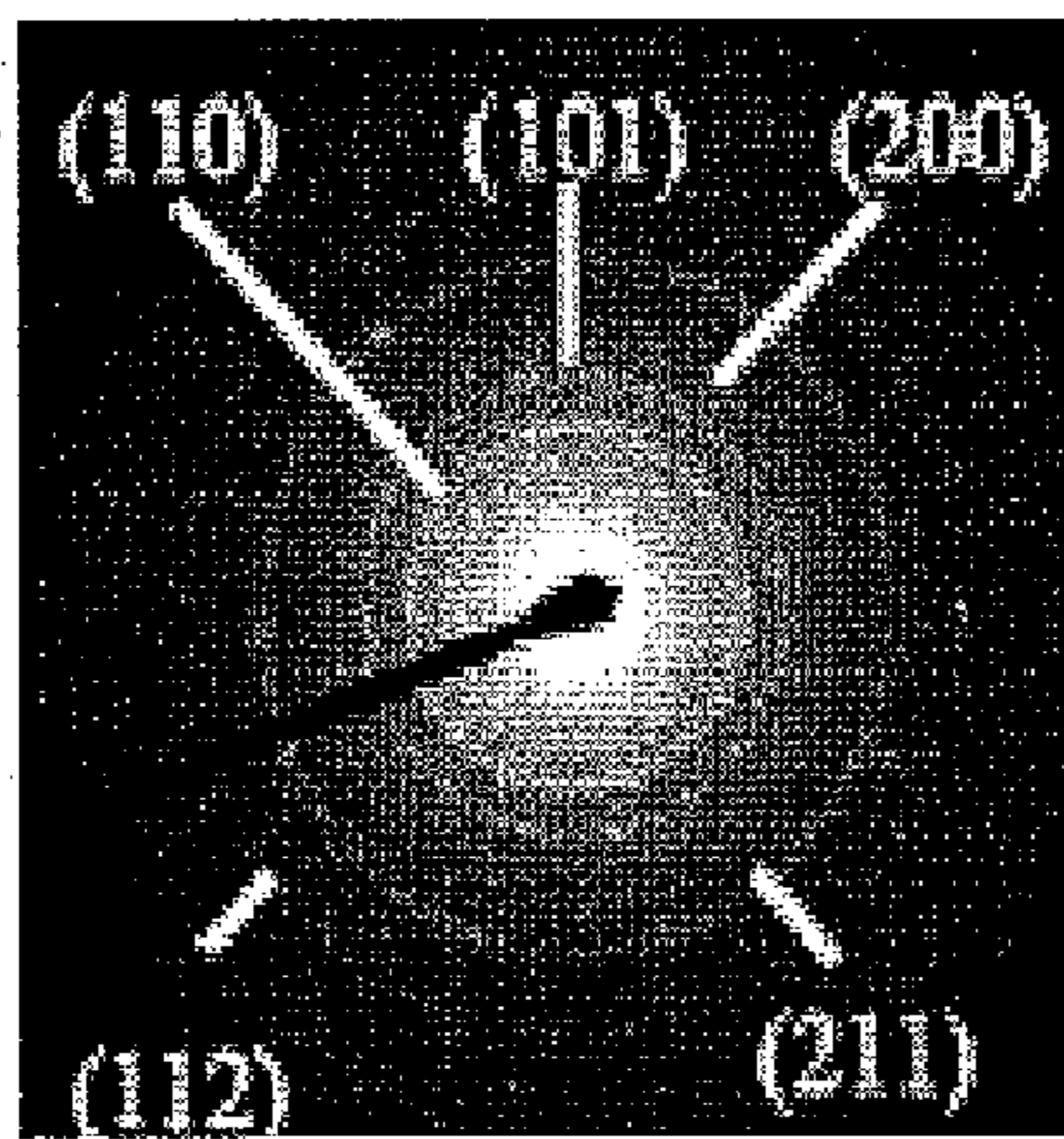


Figure 2B

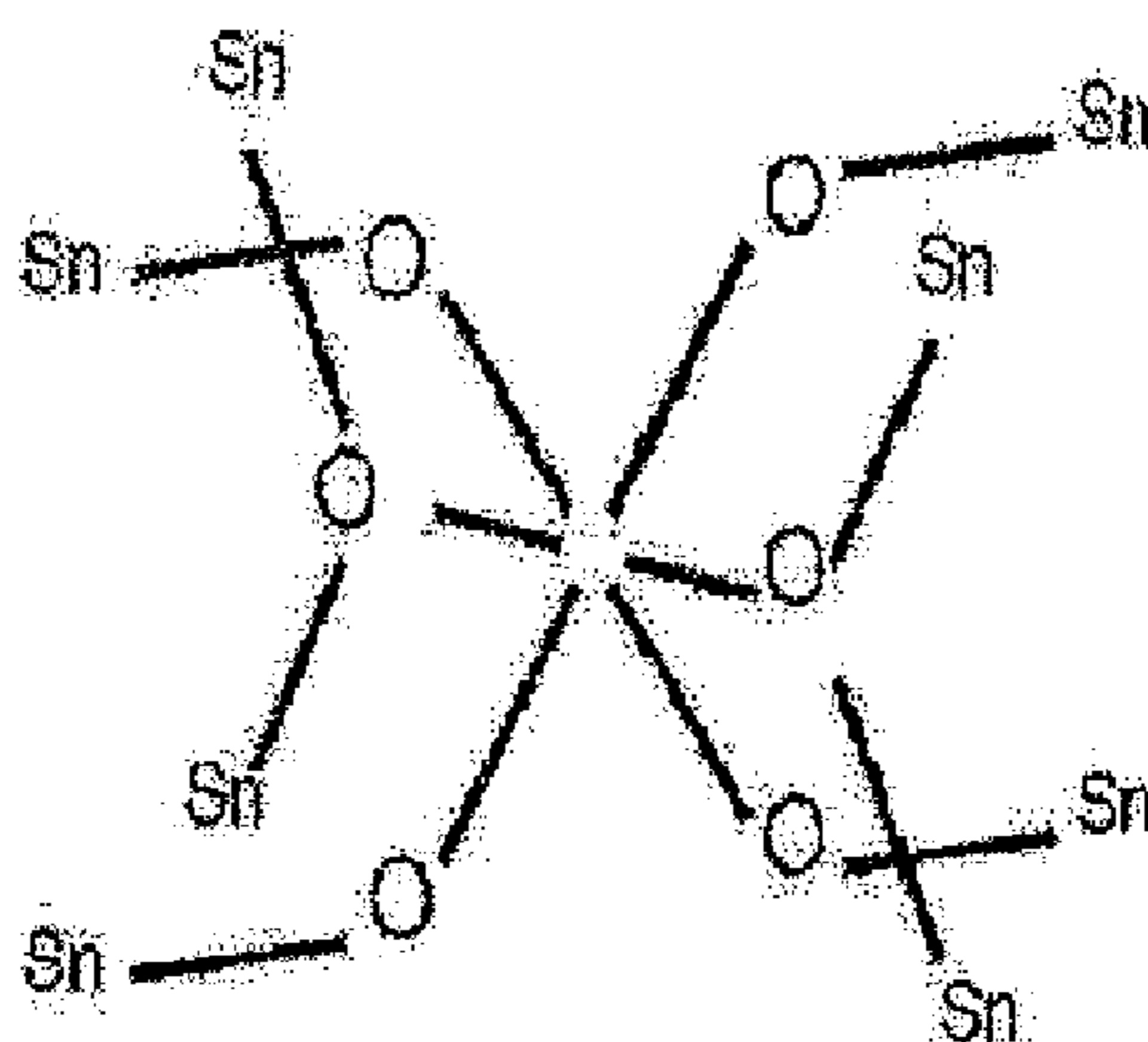


Figure 2C

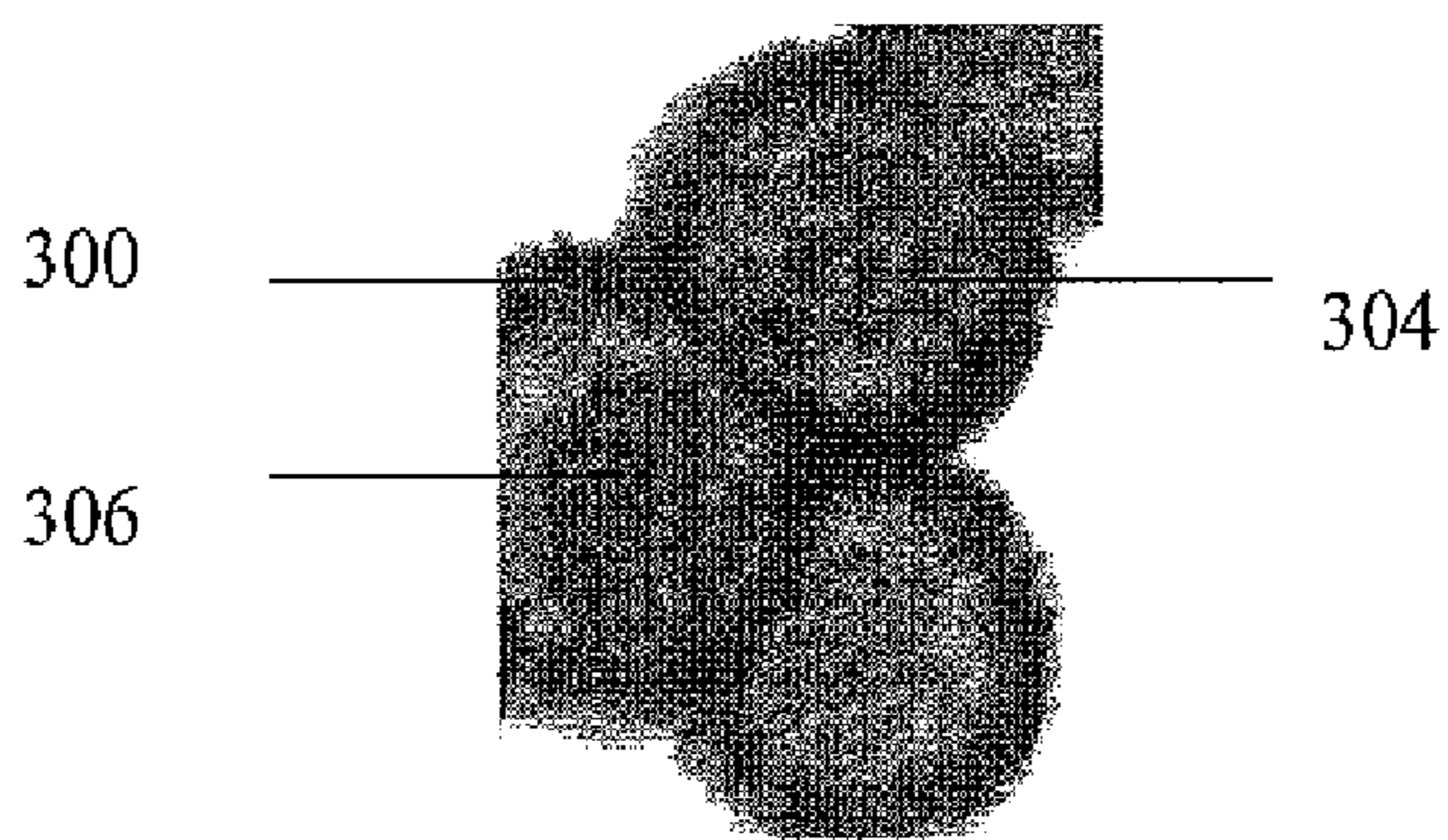


Figure 3

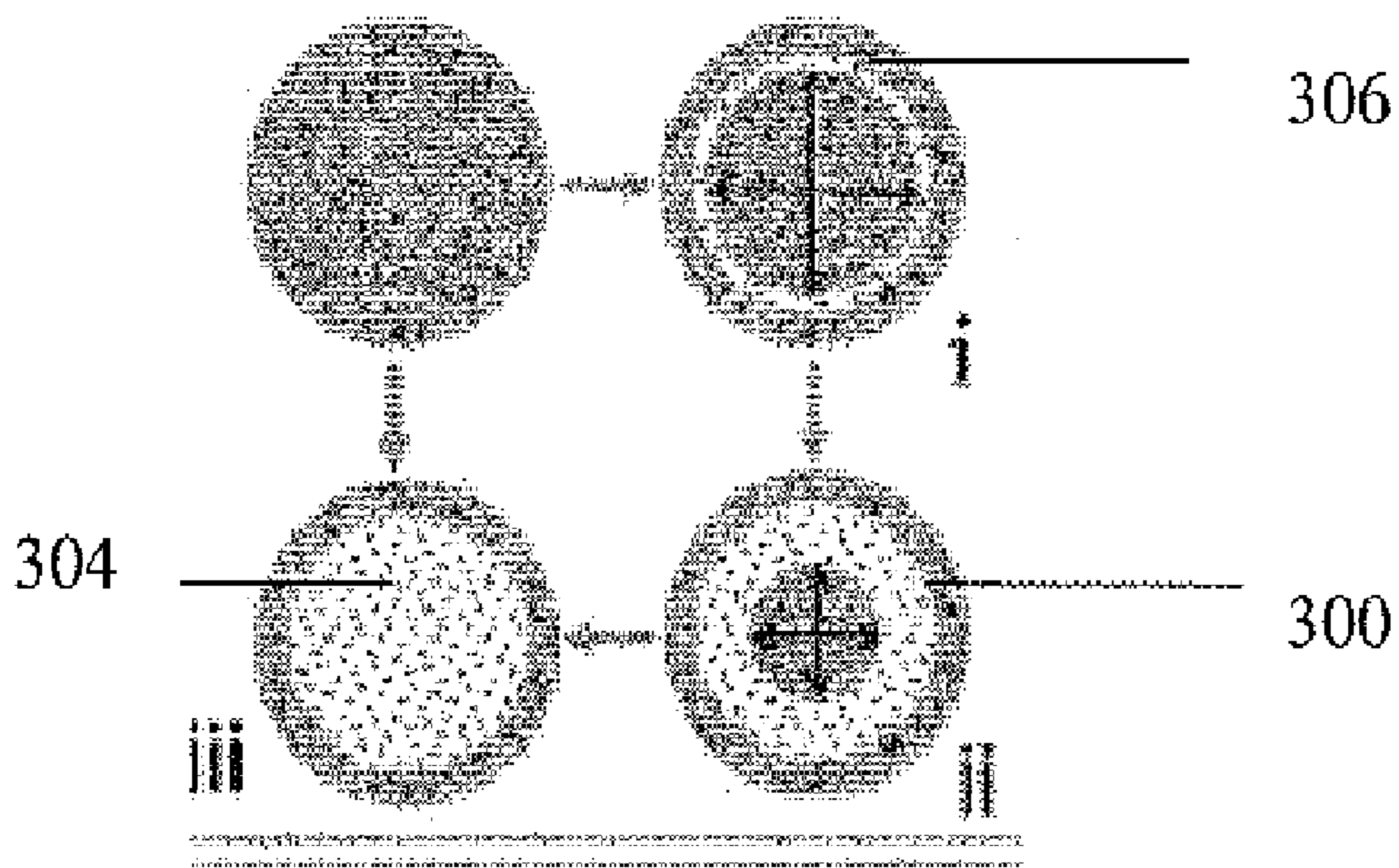


Figure 4

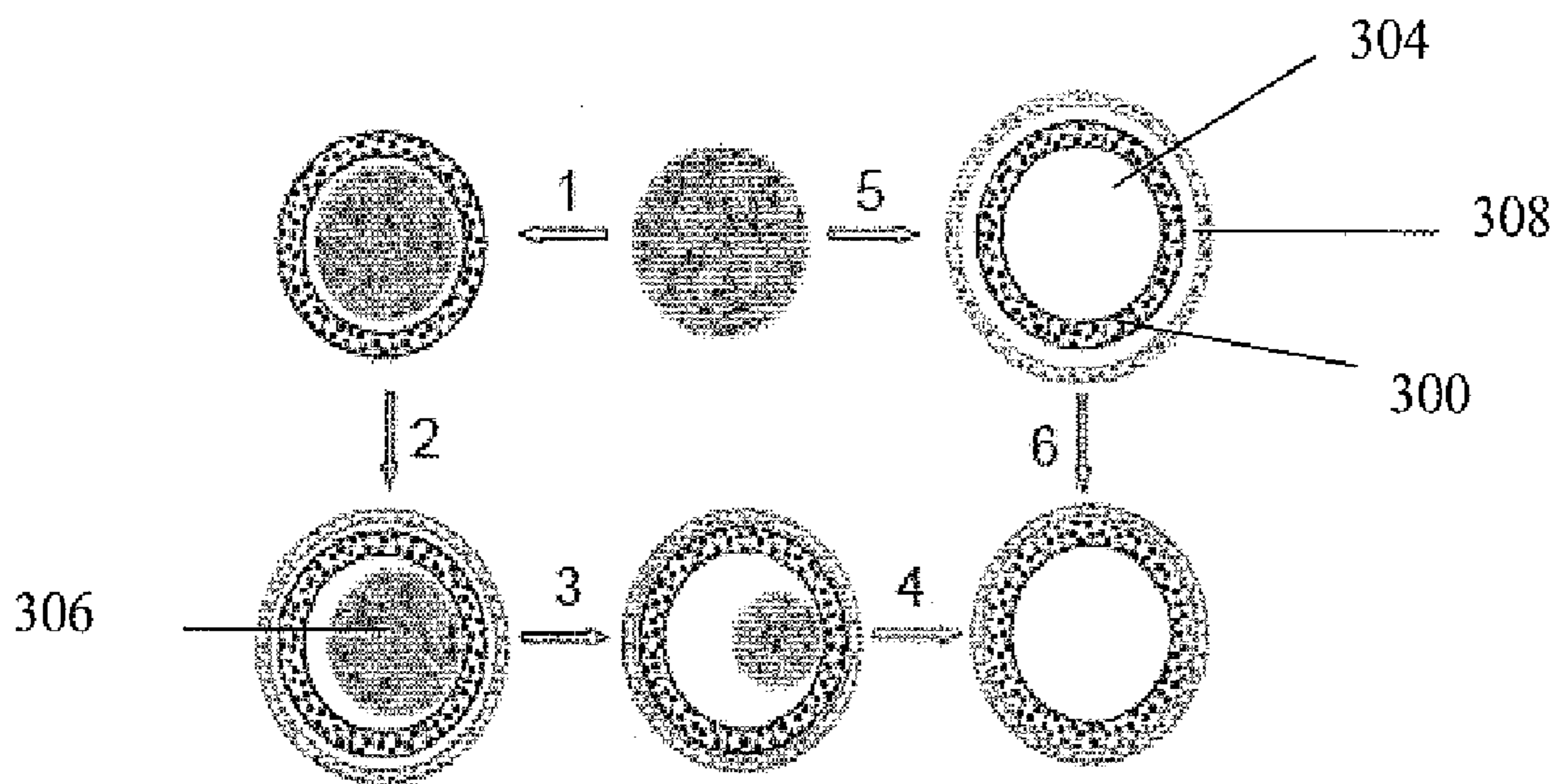
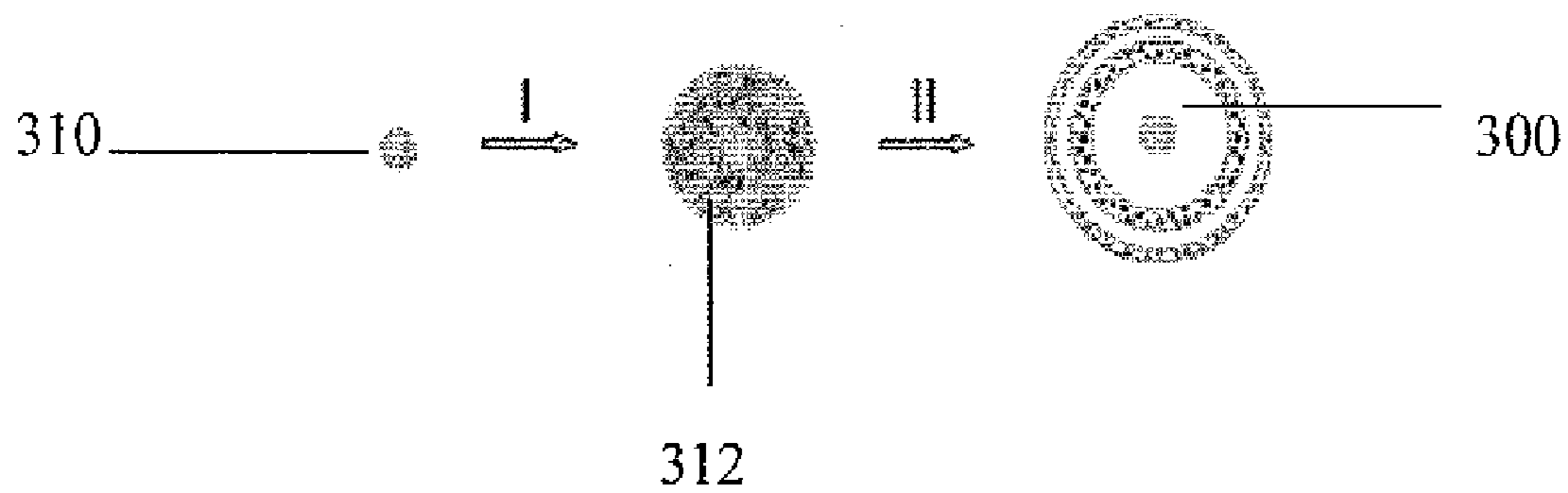
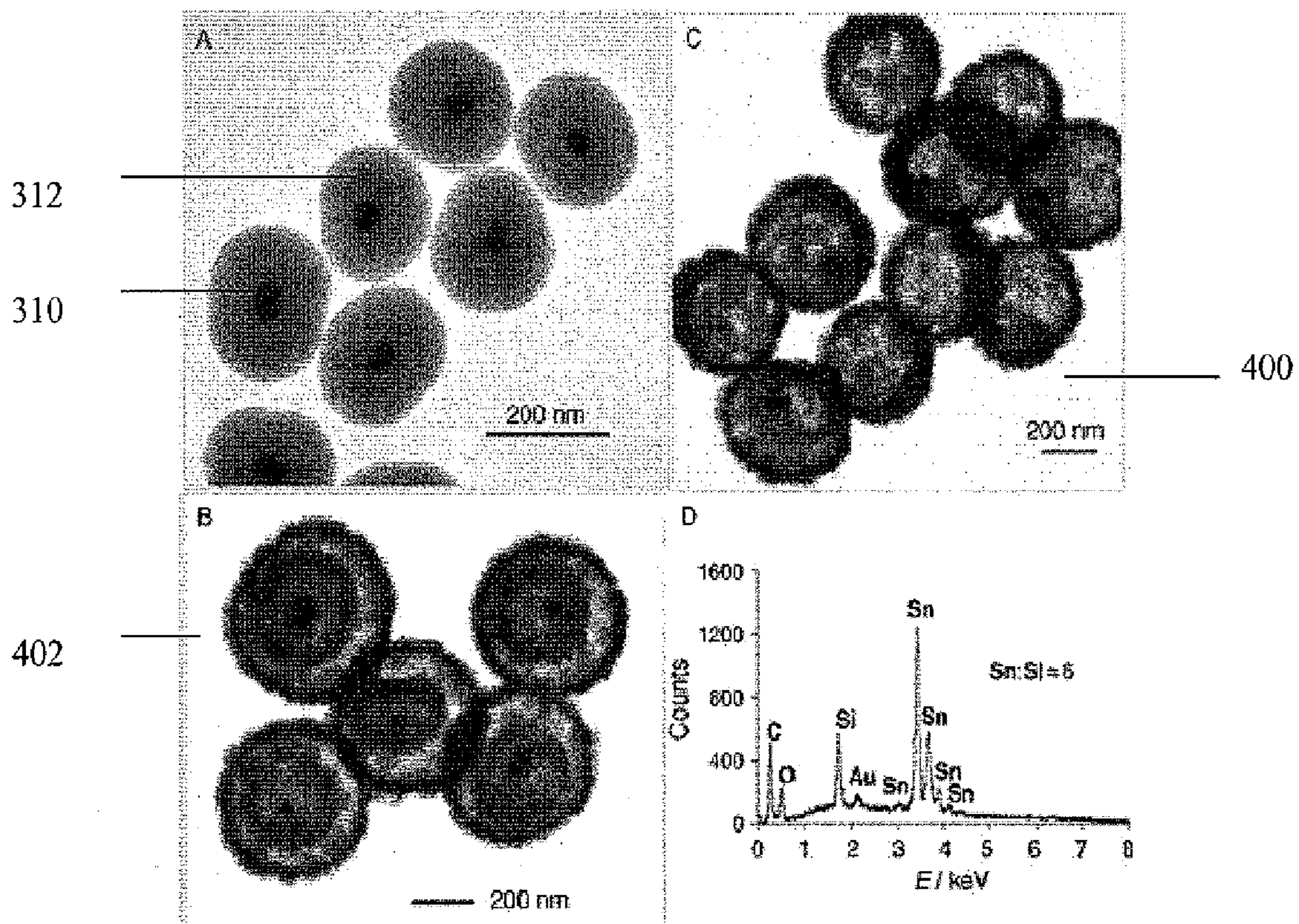


Figure 5



Figures 6A-6D



Figures 7A-B

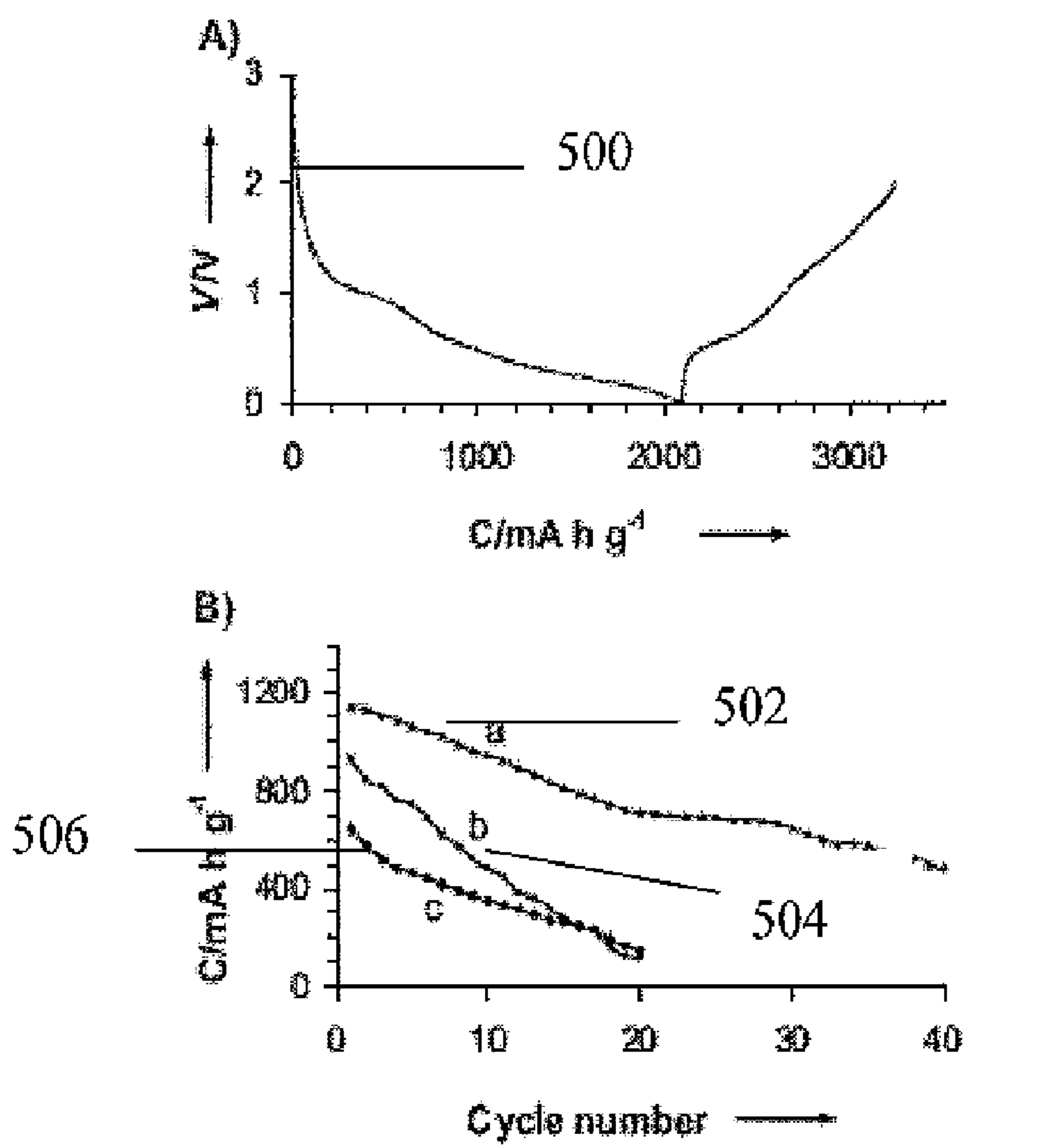
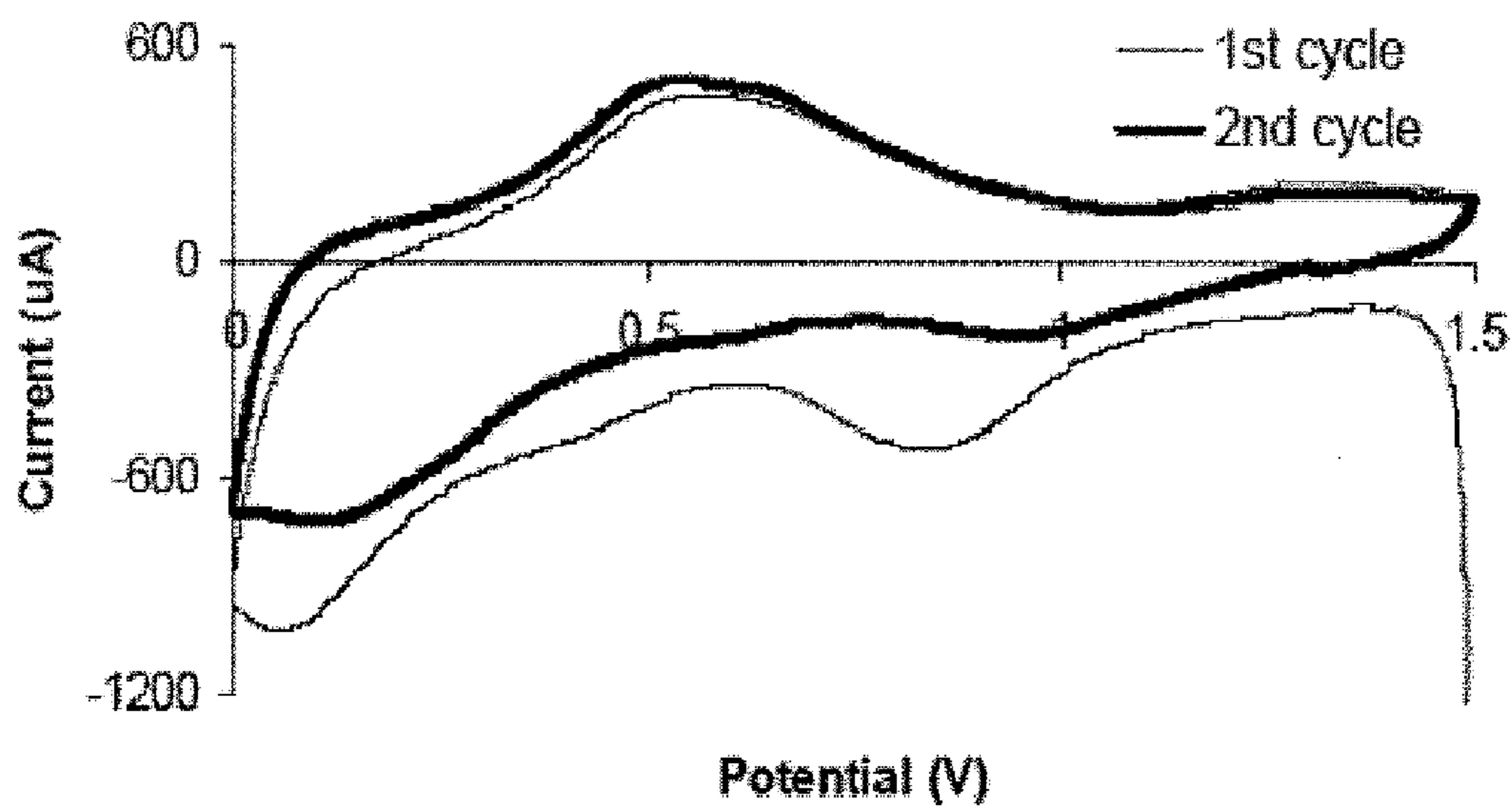


Figure 8



**NANOSTRUCTURED METAL OXIDES
COMPRISING INTERNAL VOIDS AND
METHODS OF USE THEREOF**

PRIORITY CLAIM

[0001] The present application claims priority to U.S. Provisional Pat. App. 60/804,031 filed on Jun. 6, 2006, the contents of which are hereby incorporated by reference in their entirety.

STATEMENT OF GOVERNMENT RIGHTS

[0002] This invention was made with Government support under contract number DMR 0404278, awarded by the National Science Foundation. The government has certain rights in this invention.

FIELD OF INVENTION

[0003] The present invention relates to nanostructures and more particularly to nanostructures comprising nanostructured metal oxide shells enclosing internal voids, as well as methods for making and using the same.

BACKGROUND

[0004] Recently, hollow inorganic micro- and nanostructures have attracted considerable attention because of their promising applications as nanoscale chemical reactors, catalysts, drug delivery carriers, semiconductors, and photonic building blocks. X. W. Lou, C. Yuan, Q. Zhang, L. A. Archer, *Angew. Chem. Int. Ed.* 2006, 45, 3825. In particular, nanostructures comprising metal oxides may be used as semiconductors in applications such as gas sensors and lithium rechargeable batteries. Y. Wang, X. Jiang, Y. Xia, *J. Am. Chem. Soc.* 2003, 125, 16176; M. Law, H. Kind, B. Messer, F. Kim, P. Yang, *Angew. Chem. Int. Ed.* 2002, 41, 2405; Y. Idota, T. Kubota, A. Matsufuji, Y. Maekawa, T. Miyasaka, *Science*, 1997, 276, 1395. However, although metal oxides (for example, tin oxide (SnO₂)) generally have a much higher theoretical specific lithium storage capacity area than more traditionally used materials such as graphite, the large volume changes in metal oxide nanostructures during charging/discharging processes result in poor cyclability, thus limiting their use in such applications. S. Han, B. Jang, T. Kim, S. M. Oh, T. Hyeon, *Adv. Funct. Mater.* 2005, 15, 1845; K. T. Lee, Y. S. Jung, S. M. Oh, *J. Am. Chem. Soc.* 2003, 125, 5652; Y. Wang, H. C. Zeng, J. Y. Lee, *Adv. Mater.* 2006, 18, 645. One possible strategy to mitigate this problem and further enhance structural stability is to use hollow nanostructures. Such hollow nanostructures have higher surface to volume ratios which allow for greater charge capacities than solid nanostructures. Hollow nanostructures may be designed in various shapes and sizes, and commonly include nanoparticles, nanorods/belts/arrays, nanotubes, nanocylinders, nanococoons, nanodisks, nanoboxes, nanospheres, among others.

[0005] At present, there exist numerous methods for the preparation of hollow metal oxide nanostructures. One approach involves the use of various removable or sacrificial templates, including, for example, monodispersed silica, carbon or polymer latex spheres, reducing metal nanoparticles, and even emulsion droplets/micelles and gas bubbles. Q. Peng, Y. Dong, Y. Li, *Angew. Chem. Int. Ed.* 2003, 42, 3027-3030. Although conceptually simple and versatile, such methods are often burdened with the challenge of uniformly depositing metal oxides (or their precursors) on templates, a

problem which has traditionally been dealt by prior surface modification, itself a tedious process. M. Yang, J. Ma, C. Zhang, Z. Yang, Y. Lu, *Angew. Chem. Int. Ed.* 2005, 44, 6727. Other templating methods such as templating sol-gel precursors with colloidal crystals or their replicas (often called the "lost-wax approach") result in amorphous and structurally fragile nanostructures upon crystallization at high temperatures and upon template removal. Z. Zhong, Y. Yin, B. Gates, Y. Xia, *Adv. Mater.* 2000, 12, 206-209.

[0006] Other approaches, which are template free, employ mechanisms such as corrosion-based inside out evacuation and the nanoparticle Kirkendall effect. Y. D. Yin, R. M. Rioux, C. K. Erdonmez, S. Hughes, G. A. Somorjai, A. P. Alivisatos, *Science* 2004, 304, 711. However, many such existing methods for the production of nanostructures are often cumbersome involving multiple steps that are often difficult to control, and are cost-prohibitive which prevent them from being used in large-scale applications. Moreover, many of these existing methods also result in poor yields of mono-disperse, hollow nanostructures, producing mixed hollow and solid nanostructures, or nanostructures with large-size distributions.

[0007] Thus, there exists a need for improved hollow metal oxide nanostructures comprising a relatively high surface to volume ratio (and thus a large number of potential active sites) and physical stability. There also exists a need for viable industrially scaleable methods of producing such hollow metal oxide nanostructures at low cost, high yields, narrow-size dispersions, geometric stability and homogeneous morphologies.

SUMMARY OF THE INVENTION

[0008] In one aspect, the present invention relates to nanostructures of metal oxides, comprising a nanostructured shell defining an internal space, internal cavity, or "internal void." The nanostructures may be nanoparticles, nanorods/belts/arrays, nanotubes, nanocylinders, nanodisks, nanoboxes, nanospheres, nanococoons, nanospindles, among other nanostructures. In one embodiment, the nanostructure comprises a metal oxide nanosphere comprising an outer shell defining a completely hollow cavity. In another embodiment, the nanostructure comprises an inner hollow cavity comprising an internal core. In yet another embodiment, the nanostructures comprise two or more nanostructured metal oxide concentric shells surrounding an inner cavity, while in another embodiment, such nanostructured metal oxide concentric shells surrounding the inner space are in turn separated by intervening spaces. In yet another embodiment, the nanostructures may comprise a plurality of pores in one or more of the nanostructured walls. In other embodiments, the nanostructures comprise additional materials in the inner space, for example, materials bearing magnetic or electrical properties, for example ferric oxides including, but not limited to, Fe₂O₃, Fe₃O₄, CoFe₂O₄, as well as other metal oxides like CO₃O₄, ZnO, CuO, Cu₂O, or even metal sulfide semiconductors like CdS, ZnS, etc. Materials with other functional properties, including noble metals, like Au, Ag, Pt, Pd, etc., may also be enclosed within the inner space of the nanostructures of the invention. When the nanostructures are synthesized using templates comprising silica, latex, carbon, or gels, the inner space of the nanostructure may comprise cores of varying sizes of the template material used. In preferred embodiments, the nanostructures are made of tin oxides, but may also comprise oxides of titanium, zirconium, boron, aluminum,

germanium, indium, gallium, hafnium, silicon, vanadium, or tantalum, zinc, copper, iron, nickel, copper and combinations thereof.

[0009] In another aspect, the present invention is directed to novel inexpensive, viable, high-yield methods for large-scale and industrial mass production of such hollow metal oxide nanostructures. In one embodiment, the invention comprises a template-free “one-pot” method, based on an inside-out Oswald ripening mechanism. This method comprises hydrothermal treatment of a metal-oxide precursor in a mixed solvent, usually a polar solvent in and water, and the mediation of general ionic and non-ionic surfactants, polymers, or crystal modifiers such as urea-based compounds at temperatures above about 140° C. and up to about 200° C. that allow for high-yield mass production of hollow metal oxide nanostructures with controllable sizes in the range of 200.0-500.0 nm.

[0010] In yet another aspect, the invention is drawn to a novel hydrothermal shell-by-shell templating strategy suitable for the preparation of polycrystalline monodisperse metal oxide hollow nanostructures with nanostructured metal oxide shells. Unlike existing methods, the hydrothermal shell-by-shell templating method of the invention requires no prior surface modification of the template, making this method both easier to use and less costly than existing methods. In one embodiment, the metal oxide hollow nanostructures are multi-shelled which leads to greater physical stability. In another embodiment, these single or multi-shelled nanostructures are functionalized with other functional nanoparticles (e.g., materials with magnetic properties, materials with good heat and electrical conductivity properties, etc.). The deposition protocol taught by the invention can be applied to a variety of template materials, including both silica and non-silica templates, and to templates having varying shapes, sizes and symmetries. In one embodiment, the nanostructures produced by this method may be coated with additional magnetic or semiconductor materials.

BRIEF DESCRIPTION OF THE DRAWINGS

[0011] Certain embodiments of the present invention are illustrated by the accompanying figures. It should be understood that the figures are not necessarily to scale and that details not necessary for an understanding of the invention or that render other details difficult to perceive may be omitted. It should be understood, of course, that the invention is not necessarily limited to the particular embodiments illustrated herein.

[0012] FIGS. 1A, B, and C depicts a cross-sectional schematic diagram of nanostructures comprising various shell-like structures enclosing a hollow internal void.

[0013] FIG. 2A depicts the ring-like selected area electron diffraction pattern (“SAED”) pattern shown by the SnO₂ in the nanostructured shell. FIG. 2B depicts the rutile tetragonal structure of SnO₂. FIG. 2C is a magnified energy filtered Transmission electron microscope (“TEM”) image of a SnO₂ nanosphere.

[0014] FIG. 3 illustrates cross-sectional diagrams of the inside-out ripening mechanism that forms the basis of the one-pot template-free synthesis of a metal oxide hollow nanostructure.

[0015] FIG. 4 illustrates the shell-by-shell template-based method of preparing a SnO₂ nanosphere.

[0016] FIG. 5 depicts cavity functionalization of a nanosphere with an Au nanoparticle.

[0017] FIGS. 6A and 6B depict TEM images of Au/silica core/shell particles and double-shelled Au/SnO₂ hollow colloids prepared via steps I and II of FIG. 5, respectively; FIG. 6C shows Au/SnO₂ hollow colloids obtained by HF etching the colloids shown in FIG. 5B; FIG. 6D depicts the EDX spectrum of the particles shown in FIG. 5.

[0018] FIG. 7A depicts a first cycle charge-discharge curve for SnO₂ hollow nanospheres. FIG. 7B illustrates the comparative cycling performance of various nanostructures.

[0019] FIG. 8 illustrates cyclic voltammograms of hollow SnO₂ nanospheres (first and second cycle). The scan range of 0-1.5 V (vs. Lithium) was swept at the rate of 0.1 mV/s).

DETAILED DESCRIPTION

[0020] The hollow nanostructures of the present invention comprise one or more polycrystalline metal oxide nanostructured shells enclosing an inner cavity or “internal void.” As used herein, the terms cavity and void are interchangeable. Various metal oxides may be employed in the invention, including, but not restricted to oxides of titanium, zirconium, boron, aluminum, germanium, indium, gallium, hafnium, silicon, vanadium, tin, tantalum, iron, nickel, cobalt, zinc, copper and combinations thereof. In preferred embodiments, the metal oxides may be tin oxide (SnO₂), titanium dioxide (TiO₂), and zirconium oxide (ZrO₂). More preferably, the metal oxide is SnO₂.

[0021] The hollow nanostructures as taught by the invention exhibit various configurations, including, but not limited to, nanoparticles, nanorod/belts/arrays, nanotube, nanodisks, nanoboxes, nanocylinders, nanospheres, nanococoons and nanospindles, among others. In one embodiment of the invention, the hollow nanostructures of the invention are symmetrical, in that they comprise at least one axis of symmetry; in other embodiments, the hollow nanostructures may be asymmetrical.

[0022] As depicted in FIGS. 1A, B, and C by way of example of a hollow nanosphere, the nanostructures of the invention comprise shell-like structures enclosing a hollow internal void. These nanostructures include, but are not limited to:

[0023] (i) a nanostructure comprising a single nanostructured shell **300** enclosing a hollow internal void **304** (FIG. 1A);

[0024] (ii) a nanostructure comprising a single nanostructured shell **300** enclosing a hollow internal void **304**, in which is contained a solid or nanostructured inner core **306** (FIG. 1B);

[0025] (iii) a multiple-shelled nanostructure comprising a single nanostructured shell **300** and at least one additional concentric nanostructured shell **308** enclosing a hollow internal void **304**, which optionally comprises a solid or nanostructured inner core **306** (FIG. 1C). As defined herein, the term “concentric” is not limited to circular shells, or shells that share a common center, but is meant to define shells that are “one inside the other.”

[0026] In the embodiment in which the nanostructure comprises multiple nanostructured shells, the shells may be in direct contact with each other at one or more points on their respective surfaces, in full contact at all points on their respective adjacent surfaces, or may be separated by an intervening void. The intervening void may be completely hollow or may comprise an additional material. As stated above, the basic

cross-sectional elements of the nanostructures as depicted are applicable to varying cross-sectional shapes, forms, and sizes.

[0027] Typically, the average cross-sectional distance of the nanostructure, depending on its shape and morphology, may vary between about 50.0 nm to about 1,000.0 nm, more particularly between about 100.0 nm and about 700.00 nm, and still more particularly between about 200.0 nm and about 500.0 nm. The average thickness of the nanostructured shells may vary from about 10.0 nm and 50.0 nm, more particularly between about 15.0 nm and 40.0 nm, and still more particularly between about 20.0 nm and about 30.0 nm. In those embodiments of the nanostructures comprising an inner core, the core typically comprises an average diameter of between about 50.0 nm and 500.0 nm, more particularly between about 200.0 nm and about 400.0 nm, and still more particularly between about 75.0 nm and about 125.0 nm.

[0028] In one embodiment, the nanostructures of the invention may comprise a single pore or a plurality of pores within one or more of the nanostructured shells. Unless stated herein, the pores may be present in any nanostructured shell anywhere on said shell. As discussed herein, the term pore may be construed as a hole of any shape or size across the entire thickness of a nanostructured shell. For those nanostructures comprising multiple nanostructured shells, the pores may be present in only one nanostructured shell, all nanostructured shells, or a subset of the nanostructured shells. In one embodiment of the invention, the pores are present in only the outermost shell. In another embodiment, the pores are present in every shell. In another embodiment, a pore in one nanostructured shell may be contiguous with a pore in an adjacent nanostructured shell. In yet another embodiment, a pore across each nanostructured shell is contiguous with a pore in the adjacent concentric shell such that the contiguous pores create an opening from the exterior of the nanostructure to the internal void.

[0029] In keeping with IUPAC notation (J. Rouquerol et al., *Pure & Appl. Chem.*, 66 (1994) 1739-1758), pores in the nanostructured shells may be macroporous pores with pore dimensions less than about 2.0 nm, macroporous with pore dimensions typically greater than about 50.0 nm, or mesoporous with pore dimensions between 2.0 and 50.0 nm. Typically, the pores in the nanostructured shells diameters between about 1.0 nm and about 10.0 nm, more particularly between about 3.0 nm and about 5.0 nm. In one embodiment, a single-shelled nanostructure may comprise a single macropore of sufficient diameter such that the resulting nanostructure resembles a cup or a bowl. In another embodiment, the presence of contiguous macropores in a multi-shelled nanostructure may result in a similar cup or bowl-like nanostructure. In yet another embodiment of the invention, the pores are formed by treating the nanostructure with a pore-forming material (porogen) followed by heating between 100 and 1,000° C. C. V. Nguyen et al., *Chem. Mater.* 11, 3080 (1999); C. Nguyen et al., *Macromolecules* 33, 4281 (2000). Heat may be applied at high temperatures in an autoclave. Alternately, the porogen-treated nanostructure may be dried at low temperatures (<0° C.) in a lyophilizer.

[0030] The nanostructured shells of the invention are polycrystalline, typically comprising a plurality of tin oxide primary metal oxide “crystallites,” which may vary in size. The average size of these primary crystallites is between about 1.0 nm and about 50.0 nm, more particularly between about 10.0 nm and about 20.0 nm.

[0031] X-ray diffraction patterns (“XRD”) conducted on a nanostructure comprising SnO₂ nanostructured shells confirm the polycrystalline nature of the nanostructured shells. The XRD patterns determined can be assigned to tetragonal rutile SnO₂ (cassiterite, JCPDS card No. 41-1445, space group: P4₂/mm, a_o=4.738 Å, c_o=3.187 Å) as is to be expected for polycrystalline SnO₂. The SAED pattern shown in FIG. 2A indicates that the nanostructures are polycrystalline and the diffraction rings from inside to outside can be indexed to (110), (101), (200), (211) and (112) planes of rutile SnO₂, respectively. The diffraction rings come from different crystal planes, with each crystal plane in a primary crystal generating a point in the SAED pattern. The rutile tetragonal structure of SnO₂ typically looks like the structure depicted in FIG. 2B, where the Sn atom is octahedrally surrounded by oxygen atoms, which, in turn, are surrounded by planar triangles of Sn atoms.

[0032] The cross-structural morphology of the metal oxide nanostructures of the invention are further illustrated by a low magnification transmission electron microscopy (“TEM”) image as shown in FIG. 2C. The SnO₂ nanospheres clearly depict the nanostructured outer shell **300**, the inner space **304** and an internal core **306**. The dark contrast inside each shell as shown in FIG. 2C reveals that the inner space is in fact filled with a solid core. Such nanostructures can be prepared using a template-free as well as the template-based methods taught by the invention and discussed herein.

[0033] As stated herein, controlled synthesis of the foregoing nanostructures may be carried out by a simple “one-pot” template-free manner or by using templates and employing a shell-by-shell deposition of the metal oxide. The one-pot template-free method based on a novel and unusual “inside-out Ostwald ripening mechanism” comprises the steps of combining metal oxide precursor with a solvent to create a mixture, optionally adding one or more yield-enhancing additives (for example, urea-based additives) to this mixture, and heating this mixture for a predetermined reaction times. These steps may be followed by cooling, centrifugation and washing with deionized water. This one-pot, template-free method taught by the invention is highly advantageous over existing methods in that it involves fewer steps than existing methods suitable for high-yield mass production of monodisperse, structurally sound metal oxide nanospheres. By way of example of the production of SnO₂ nanospheres using a potassium stannate precursor, this template-free method has been shown to give high yield mass production of SnO₂ hollow nanospheres as measured by the % of Sn units in the stannate precursor converted to SnO₂ crystallites in the end-product, and at nearly 100% morphological yield (i.e., the percentage of nanospheres displaying the same size, shape and cross-sectional characteristics).

[0034] Preferably, the precursor salt of the metal oxide is an alkali metal precursor salt, more preferably the alkali metal precursor salt is a sodium or a potassium salt, most preferably the potassium salt. Thus, when the desired metal oxide nanostructure is a SnO₂ nanostructure, the metal precursor salts may be sodium stannate or potassium stannate. The mixed solvent typically comprises a polar solvent in water, preferably a highly polar solvent with some degree of hydrophobic/surfactant character, more preferably, any C₂ to C₁₀ alcohol which may be employed as a single component or in mixture with other additives. Typically, the yield-enhancing additives used in the method comprise urea compounds (such as urea and thiourea), —NH₂ compounds (including, but not limited

to ammonia, ethylenediamine, surfactants amines, diamines, ammonia, and hydrazine), or surfactants, both ionic and non-ionic (for example, cetyltrimethylammonium bromide (“CTAB”), Tween-based compounds, dodecyl sulfates, etc.). Preferably, yield-enhancing additives are urea-based catalytic additives such as urea and thiourea. Additional yield-enhancing additives, including ammonia, ethylenediamine and surfactants such as cetyltrimethylammonium bromide (“CTAB”) may be used during synthesis. In addition, ammonia may be used as a pH modifier. Ethylenediamine and the CTAB surfactant may be used to effect the shape and size of the end product. Typically, the mixture of the metal-oxide precursor in the mixed solvent and the yield enhancing additives is heated to a temperature of between 140 and 200° C., preferably between 3 and 24 hours

[0035] By way of example, describing the formation of a hollow SnO₂ nanosphere by heating a mixture of potassium stannate in a mixed ethanol/water solvent in the presence of urea, the mechanism for the template-free formation of hollow nanostructures may be described. During the first stage of reaction, solid nanospheres are formed by hydrolysis of the stannate. With prolonged hydrothermal treatment, these solid nanospheres are transformed by the “inside-out Ostwald ripening” or “core evacuation” of the formed solid nanosphere in which the metal oxide crystals inside the solid nanosphere are forced out of the solid nanosphere to create an internal void. Ostwald ripening, first described by Wilhelm Ostwald in 1896, is a well-known particle (crystal) growth mechanism, in which the growth of large particles occurs at the expense of small ones while trying to minimize the surface energy (because of the smaller surface to volume ratio in large particles). In the case of the nanostructures of the invention, inside-out Ostwald ripening is understood to be the process by which the metal oxide crystals in the interior of the nanostructures dissolve preferentially because of the crystallization of the metal oxides on the surface of the forming nanostructures, even as the more amorphous material within the interior of the nanostructure amorphous tend to dissolve. L. Archer, X. W. Lou, *Adv. Mater.* 2006 18, 2325-2329; H. G. Yang, H. C. Zeng, *J. Phys. Chem. B* 2004, 108, 3492; J. Li H. C. Zeng, *Angew. Chem.* 2005, 117, 4416.

[0036] This inside-out ripening process may initiate at regions either just below the external surface of the solid nanosphere, or around the nanostructure center, depending on the reaction conditions. Core evacuation by either mechanism yields, respectively, hollow nanostructures or hollow nanostructures in which the internal void comprises a solid core. Since the solid nanospheres typically formed first are not typically single-crystalline but comprise many tin oxide primary crystallites, the tin oxide particles in the inner region are packed more loosely than those in the outer layer resulting in larger surface energies which can lead to the tendency to dissolve. Moreover, as the hollowing process is typically accompanied by crystallization of the particles, the primary particles in the outer surfaces are relatively easy to crystallize facilitated by surrounding solvent, and therefore less crystalline particles in the inner region are easy to dissolve.

[0037] FIG. 3A illustrates cross-sectional diagrams of the proposed inside-out ripening mechanism: inside-out evacuation can initiate from just below surface of the shell **300** to form nanostructure (i) in which the hollow inner void **304** is beginning to be formed; then evolve to form a nanostructure (ii) with a well-defined inner void **304** further comprising an inner core **306**; and further to hollow nanostructure (iii).

Alternately, inside-out ripening mechanism may start around the central region of the solid sphere and evolve to particle (iii) directly.

[0038] By carefully controlling certain key reaction parameter in the template-free method of the invention the shape, size, morphology, and yield of the resulting metal oxide nanostructure may be determined. These parameters include, but are not limited to, the type and concentration of the metal-oxide precursor, the properties of the polar solvent and the polarity of the resultant polar solvent/water mixture, the type and amount of yield-enhancing additives used, the temperature at which the mixing reaction is conducted, and the length of time for which this reaction is performed.

[0039] In one embodiment of the invention, changes in precursor concentration affect both the morphology and size of the end-product. By way of example of the production of SnO₂ nanospheres, it was determined that when the precursor concentration of potassium stannate was reduced from 8.4 mM to 4.7 mM, the product comprised discrete hollow nanospheres with diameters in the range of 50.0 nm to 200.0 nm and a shell thickness of 10.0 nm. In comparison, keeping all other reaction parameters the same, a higher precursor concentration (e.g. 22 mM) produced nanospheres comprising a core spaced apart from and surrounded by a shell at approximately the same thickness (10.0 nm), but with larger diameters, for example, between about 300.0 and about 400.0 nm as well as a highly defined inner core within the internal void.

[0040] Apart from precursor concentration, solvent characteristics are also relevant in affecting control of the end product. As stated previously, the solvent is preferably a highly polar solvent with some degree of hydrophobic/surfactant character, more preferably, any C₂ to C₁₀ alcohol which may be employed as a single component or in mixture with other additives. Typically, the polar solvents are dissolved in water to create a mixed solvent. Typically, the ratio of C₂ to C₁₀ alcohol to water used is 1:1, but ratios may range from 5:1 to 1:4 to produce similar results. By way of example of the hydrothermal template-free production of SnO₂ nanospheres in a mixed ethanol (“EtOH”)/water solvent, it was shown that the r value (EtOH v/v % in the solvent of EtOH/H₂O) or polarity of the mixed solvent is a parameter which has an effect on the resultant metal oxide nanostructures. Typically, the preferred r values are in the range of 30-50%. In general, well-defined hollow nanospheres are difficult to produce when r is lower than 30%. In order to synthesize well-defined, mono-dispersed, hollow SnO₂ nanospheres at r values <30%, the precursor concentrations must be increased than what are required for higher r values. If the r value remains fixed at less than 30%, and often even at less than 40%, aggregated clumps of small SnO₂ crystallites form, instead well-defined SnO₂ microspheres. For example, while keeping the r value fixed at 37.5% while changing the precursor potassium stannate concentrations, the products comprise mixtures of single hollow nanospheres (100-250 nm) and aggregated nanospheres at a precursor concentration of 13.5 mM, well-defined hollow nanospheres (300-550 nm) at a precursor concentration of 16.5 mM, and bowl-like large hollow spheres (450-750 nm) at a precursor concentration 19.5 mM, respectively.

[0041] In another embodiment, the effect of urea-based catalytic additives such as urea and thiourea was found to increase both the product yield (measured by the % of Sn units in the stannate precursor converted to SnO₂ crystallites in the end-product) and morphological yield to nearly 100%. As an example, hollow SnO₂ nanospheres produced in the

presence of urea, keeping all other reaction parameters the same are well dispersed with good monodispersity (usually 80-200 nm in diameter and an average shell thickness of about 20 nm).

[0042] In another embodiment of the invention, temperature of the reaction can be varied to affect changes in shape, size and morphology. By way of example, in the case of hollow SnO₂ nanospheres, it was shown that product synthesized at 150° C. comprises monodispersed hollow nanospheres with sizes in the range of 350-460 nm, while those prepared at 180° C. assume a bowl-like shape at a similar size. In another embodiment of the invention by way of example of hollow SnO₂ nanospheres, the hydrothermal reaction period was shown to affect the final product. While the size of the SnO₂ nanospheres obtained in the presence of thiourea at different hydrothermal reaction times do not typically increase with longer reaction times, their shell thicknesses may decrease from ~50 nm to ~20 nm, illustrating the continuing evacuation of SnO₂ nanospheres thus increasing the size of the inner void, while at the same time decreasing the thickness of the nanostructured shell. Other time-dependent experiments in which all other synthesis conditions except reaction times were kept identical, the size distribution of the nanospheres appeared largely unaltered, while the morphology changed. Specifically, the product comprised solid nanospheres after a reaction time of 6 hours, and hollow nanospheres when allowed to react for 24 hours.

[0043] The present invention also teaches a novel template based shell-by-shell nanostructure synthesis. Unlike existing methods of preparing nanostructures, the shell by shell synthesis taught by the invention creates nearly mono-disperse, narrow-size distribution, hollow nanostructures.

[0044] Unlike existing methods taught in the prior art where the templates are pre-treated, the method as taught by the invention requires no prior surface modification of the template resulting in both time and cost-savings over existing methods for producing nanostructures. In particular, the advantages of this method allow this method to be used in large-scale and industrial scale applications. The deposition protocol involves direct treatment of the template with the metal oxide precursor in the presence of a mixed solvent and a catalyst which creates a polycrystalline nanostructured metal oxide shell over the template. In one embodiment of the invention, the method may be used to create a single nanostructured shell, while in other embodiments, the deposition protocol is successively repeated to create two or more polycrystalline nanostructured shells such that each newly created shell surrounds the prior formed shell. The shell-by-shell deposition protocol as taught by the invention may be used on any suitable template including, but not restricted to, templates made of silica, latex, carbon, gels, micelles, or combinations thereof. The shell-by-shell deposition protocol may also be used on templates of any shape, including, but not restricted to, spherical, polyhedral, cylindrical templates as well as any other symmetrical or asymmetrical templates. It has also been shown that the shell-by-shell synthesis as taught by the invention can work on template sizes in which the size of the template as measured by its longest cross-sectional distance is between 50.0 to 1,000.0 nm, preferably between 150.0 to 500M nm, and more preferably between 200.0 to 300.0 nm.

[0045] By way of example only, the shell-by-shell synthesis of the invention may be illustrated by the formation of polycrystalline SnO₂ nanospheres as depicted in FIG. 4. The

SnO₂ precursor is first hydrothermally deposited on silica nanospheres to form a single nanostructured shell **300** as shown in Step 1. This single nanostructured shell then serves as an interim nanotemplate for further deposition. This deposition step may be repeated to form double shells **308** as shown in Step 2. As formed, the double-shelled nanostructures still contain partially dissolved silica cores **306**, the sizes of which may be controlled by “etching” (or dissolution) with dilute HF (typically about 1-2% wt %) to form either a hollow inner void **304** with an internal core **306** comprising the unetched template material (Step 3), or proceed to form a completely hollow inner void **306** (Step 4). Double-shelled hollow nanostructures can also be formed in a single step by increasing the relative amount of silica template (Step 5). By increasing the extent of HF etching, the double-shelled hollow nanostructures can be transformed into a single shell hollow nanostructure (Step 6). Typically, the hydrothermal deposition of SnO₂ is carried out under basic conditions at a pH between 9 and 12, more preferably between 10 and 11.

[0046] As with the one-pot template-free method described herein, preferably, the precursor salt of the metal oxide is an alkali metal precursor salt, more preferably the alkali metal precursor salt is a sodium or a potassium salt, most preferably the alkali metal precursor salt is a potassium salt. Thus, when the desired metal oxide nanostructure is a SnO₂ nanostructure, the metal precursor salts may be sodium stannate or potassium stannate. The mixed solvent typically comprises a polar solvent in water, preferably a highly polar solvent with some degree of hydrophobic/surfactant character, more preferably, any C₂ to C₁₀ alcohol which may be employed as a single component or in mixture with other additives. Typically, the yield-enhancing additives used in the method comprise urea compounds (such as urea and thiourea), —NH₂ compounds (including, but not limited to ammonia, ethylenediamine, surfactants amines, diamines, ammonia, and hydrazine), or surfactants, both ionic and non-ionic (for example, cetyltrimethylammonium bromide (“CTAB”), Tween-based compounds, dodecyl sulfates, etc.) Preferably, yield-enhancing additives are urea-based additives such as urea and thiourea. In addition, ammonia may also be used as a pH modifier. Ethylenediamine and the CTAB surfactant may be used to effect the shape and size of the end product. Typically, the mixture of the metal-oxide precursor and the template in the mixed solvent (and optionally the yield enhancing additive) is heated in an autoclave to a temperature of between 100 and 1000° C., preferably between 120 and 200° C., most preferably between 140 and 180° C.

[0047] Various parameters are known to affect the shell-by-shell synthesis of the metal oxide nanostructures. For instance, depending on the kind of metal oxide nanostructure desired, the synthesis was found to have an optimal precursor concentration. By way of example, using the production of SnO₂ nanospheres, and keeping the precursor concentration at a concentration of 16 mM, it was determined that using silica template amounts of 100 to 160 mg, more preferably 120 to 140 mg result in single-shelled nanostructures. When the amount of silica template is reduced from 120 mg to 80 mg, some double-shelled nanostructural formation is observed, but only in the form of irregular SnO₂ crystallites. Only when the amount of silica template is further reduced to between 30 and 50 mg, more preferably 40 to 45 mg, are well-formed double-shelled hollow nanostructures observed.

[0048] The size of the inner cavity may be controlled by the extent of HF etching. For instance, for those double-shelled

nanostructures bearing an internal silica core, continuous HF etching leads to the greater dissolution of the inner silica core and the simultaneous enlarging of the inner cavity, while also causing the dissolution of the nanostructured double-shell into a single shell. L. Archer, X. W. Lou, *Small* 2006 0000, 00, No. 0 1-5 (Manuscript available at www.small-journal.com).

[0049] For those nanostructures with only one shell, the structural integrity of a single-shelled nanostructure may be enhanced either by the creation of one or more additional shells or by a post-synthesis annealing process carried out at temperatures between 400 to 600° C., more preferably between 500 and 550° C. Alternately, structural integrity may also be enhanced by increasing the deposition temperature from a range of about 140 to 160° C. to between 180 to 200° C.

[0050] The present invention allows for the exploitation of the single or multi-shelled hollow nanostructures by functionalizing the inner cavity with potentially useful nanoparticles. In one embodiment of the invention, the inner cavities may be functionalized with magnetic nanoparticles by first coating the nanoparticle with the template material. Magnetic nanoparticles include, but are not limited to, nanoparticles comprising ferric oxides including, but not limited to, Fe₂O₃, Fe₃O₄, CoFe₂O₄, as well as other metal oxides like CO₃O₄, ZnO, CuO, Cu₂O, or even metal sulfide semiconductors like CdS, ZnS, etc. Materials with other functional properties, including noble metals, like Au, Ag, Pt, Pd, etc., may also be enclosed within the inner space of the nanostructures of the invention. The template material may include any suitable material that may be coated onto said magnetic nanoparticle. Template materials include, but are not limited to, latex, silica, gels, carbon, or combinations thereof. Such functionalized nanostructures with magnetized functionalities may be used in applications such as targeted drug delivery, separation methods, biomedical imaging, and use in photovoltaic cells among others. In one preferred embodiment of the invention, SnO₂ is deposited on an α-Fe₂O₃ nanosphere, nanococoon, or nanospindle by the shell-by-shell synthesis taught by the invention to form the corresponding uniform multi-shelled SnO₂ nanostructure.

[0051] In yet another embodiment of the invention, noble metals including, but not limited to Au, Ag, Pt, Pd, etc. are treated with a template material and then subjected to a metal oxide shell-by-shell nanostructure synthesis as taught by the invention to create a mixed metal/metal oxide nanostructure functionalized to serve a particular end use. In one preferred embodiment of the invention, the functional metal is gold, while the metal oxide is SnO₂. Using the shell-by-shell synthesis of the invention, a mixed Au—SnO₂ metal-semiconductor composite nanostructure is created that is suitable for use in applications such as sensors, catalysts, controlled release drug delivery systems and bioseparations. The process by which an Au nanoparticle is functionalized within a hollow SnO₂ nanostructure is shown in FIG. 5. Step 1 involves the conformal coating of Au nanoparticles **310** with uniform shells of silica **312**. The as-obtained Au/silica nanoparticle are then used as the template for subsequent SnO₂ deposition to form a SnO₂ shell **300** in Step II. FIGS. 6A and 6B depict TEM images of Au/silica core/shell particles **400** and double-shelled Au/SnO₂ hollow colloids **402** prepared via steps I and II of FIG. 5, respectively; FIG. 6C shows Au/SnO₂ hollow colloids obtained by HF etching the colloids

shown in FIG. 5B; FIG. 6D depicts the energy dispersive X-ray (“EDX”) spectrum of the particles shown in FIG. 5B.

[0052] The polycrystalline metal oxide nanostructures of the invention generated by the methods taught herein, may also be coated with additional industrially useful materials. In one embodiment, the metal oxide nanostructures of the invention may serve as templates to be coated with materials bearing electrical conductivity properties, where optionally the metal oxide nanostructures bear electrical conductivity properties as well. In a preferred embodiment, the metal oxide nanostructures are SnO₂ nanostructures that are coated with semiconductors including, but not limited to, poly(vinylidene fluoride) (“PVDF”), hexafluoropoly(vinylidene fluoride) semiconductor (“PVDF-HFP”), and carbon-black filled PVDF or PVDF-HFP. For those nanostructures used as semiconductors in new generation lithium batteries, the added presence of such conductors on the metal oxide nanostructures enhances cyclability by improving the contact between the nanostructure and the battery. L. Archer, X. W. Lou, *Adv. Mater.* 2006 18, 2325-2329; Xinlu Li, Feiyu Kang, and Wanci Shen, *Electrochem. Solid-State Lett.*, 2006, 9, A126-A129.

[0053] The metal oxide nanostructured materials of the present invention may be used in a variety of applications. For example, the materials may be utilized as nanoscale chemical reactors, catalysis and photocatalysts, photovoltaic devices and as the anode in lithium storage batteries.

[0054] When used as anode materials in lithium ion batteries, nanostructured SnO₂ made in accordance with the present invention exhibits enhanced electrochemical properties. One hindrance against use of Sn-based anode materials in lithium ion batteries is the large volume change exhibited by Sn-based particles, owing to particle shattering and agglomeration during charging/discharging processes which leads to poor cyclability. The hollow nanostructures of the invention mitigate this problem. SnO₂ nanostructures of the present invention exhibit initial discharge capacities between about 1000.0 mAh/g and 1,300 mAh/g and more particularly between about and about 1,100 and 1,200 mAh/g and still more particularly greater than 1,100 mAh/g. Additionally, the nanostructures may undergo between about 25 and 45 cycles and more particularly between about 30 and 40 cycles while still functioning effectively at a discharge capacity of at least 300 mAh/g. It is believed that the superior lithium storage capacity is associated with the unique structure of hollow nanospheres with porous shells formed during the inside-out evacuation process.

EXAMPLES

[0055] The present invention is illustrated, but in no way limited by the following examples.

Example 1

[0056] Hollow SnO₂ nanoparticles were prepared by a hydrothermal method in an ethanol/H₂O mixed solvent. Potassium stannate trihydrate (K₂SnO₃·3H₂O, Aldrich, 99.9%) was added to 30 ml of ethanol/H₂O mixture with an r value of 25-50%, to achieve potassium stannate concentrations of 4.7 mM-40 mM. After gentle shaking by hand for about 5 minutes, a slightly white translucent or clear solution (depending on values of r and c) was obtained, which was then transferred to a 40 mL Teflon-lined stainless steel autoclave. In certain experiments, urea, thiourea or ethyl diamine

were also used as additives, typically with overall concentrations of about 0.1 mM. After heating in an electric oven at 150° C. for a period of 3-48 hours, the autoclave was gradually cooled down in air, or rapidly using tap water. The white product was harvested by centrifugation and washed with deionized water and ethanol before drying at 50° C. overnight.

[0057] The electrochemical properties of the hollow SnO₂ nanospheres were characterized at room temperature. For these measurements SnO₂ nanospheres were used to form the negative electrode in rechargeable lithium-ion batteries. The working electrode comprised 80 wt % of the active material (hollow SnO₂), 10 wt % of conductivity agent (carbon black, Super-P), and 10 wt % of binder (polyvinylidene difluoride, PVDF, Aldrich). Lithium foil was used as the counter and reference electrodes. The electrolyte was 1 M Li PF₆ in a 50:50 w/w mixture of ethylene carbonate and diethyl carbonate. Cell assembly was carried out in a glove box with the concentrations of moisture and oxygen below 1 ppm. The room-temperature electrode activities were measured using a Maccor-Series-2000 battery tester (Maccor, Inc. Tulsa, Okla.). The cells were charged and discharged at a constant current of ~0.2 C and the fixed voltage limits were between 2 V and 5 mV. Cyclic voltammetry was performed on an EG&G model 273 potentiostat/galvanostat (Princeton Applied Research, Oakridge, Tenn.) using the active anode as the working electrode and lithium as both the counter and reference electrodes. FIG. 7A shows the first cycle charge-discharge curve of SnO₂ hollow nanospheres 500. It is apparent from FIG. 7A that the SnO₂ hollow nanospheres display a very large initial discharge capacity of about 1140 mAh/g. This value is more than 75% greater than that of pristine SnO₂ nanoparticles which display an initial discharge capacity of about 645 mAh/g and also higher than, any other previously reported SnO₂ based hollow structures. FIG. 7B compares the cycling performance of as-prepared SnO₂ hollow nanospheres of the invention (curve a) 502 with pristine SnO₂ hollow nanospheres synthesized in accordance with the methods outlined in *J. Power Sources* 2005, 144, 220 by Wang and Lee (curve c) 506 and previous SnO₂ hollow nanospheres synthesized in accordance with the methods outlined in Y. Wang et al., *Chem. Mater.*, 2006, 18, 1347 (curve b) 504, which were all tested under similar conditions. It is apparent from this figure that the cycling performance of the SnO₂ hollow nanospheres of the present invention is superior.

[0058] Specifically, while all materials show some fall-off in performance over time, the capacity of the SnO₂ hollow nanospheres of the invention is still comparable to the theoretical capacity of SnO₂ after more than 30 cycles; and much higher than the theoretical capacity of graphite after more than 40 cycles.

[0059] Cyclic voltammograms, shown at FIG. 8, are consistent with previously reported SnO₂ anode materials, indicating the same mechanism for lithium storage, nanopores in the shells and the interior microcavities of hollow nanospheres should allow or at least facilitate storage of the extra amount of lithium. Specifically, FIG. 8 illustrates cyclic voltammograms of hollow SnO₂ nanospheres (first and second cycle). The scan range of 0-1.5 V (vs. Lithium) was swept at the rate of 0.1 mV/s).

Example 2

[0060] Monodisperse silica nanospheres with different sizes were prepared from the well known Stobers method. W.

Stober, A. Fink, E. Bohn, *J. Colloid Interface Sci.* 1968, 26, 62-69. Polycrystalline SnO₂ shells were facily deposited on silica templates without any prior surface modification by a hydrothermal method. Depending on the amount of nanostructures desired, 40-120 mg silica nanospheres were first dispersed by ultrasonication in 30 ml of ethanol/water (37.5 vol % ethanol) mixed solvent. To this white suspension, urea (0.9 g or 0.5 M) and potassium stannate trihydrate (~144 mg or 16 mM; K₂SnO₃·3H₂O, Aldrich, 99.9%) were added. After shaking by hand for about 5 minutes until the salt dissolved, the suspension was transferred to a 40 ml Teflon-lined stainless-steel autoclave, which was then heated in an airflow electric oven at 150-190° C. for 36 hours. After the autoclave cooled down naturally, the white product was harvested by centrifugation and washed with deionized water. This hydrothermal SnO₂ deposition can be repeated to form double and even triple shells. The silica core was etched in a dilute ethanol/water solution of HF (~2%).

Example 3

[0061] The Au/silica core/shell particles were prepared as described in detail by Liu et al. S. H. Liu, M. Y. Han, *Adv. Funct. Matter.* 2005, 15, 961-967. After extensive washing with water, the as-obtained Au/silica core/shell particles (~50 mg) were directly used without drying as the template for the same SnO₂ deposition.

Example 4

[0062] α-Fe₂O₃ spindles were prepared by aging a solution of 0.02 M FeCl₃ and 0.45 mM NaH₂PO₄ at 105° C. for 48 hours as described by Ozaki et al. M. Ozaki, S. Kratochvili, E. Matijevic, *J. Colloid Interface Sci.*, 1984, 102, 146-151. For SiO₂ coating, 63 mg α-Fe₂O₃ spindles were first dispersed by ultrasonication in a mixture consisting 650 mL of 2-propanol and 65 mL of deionized water, followed by 60 mL of ammonia (29.6%). Under magnetic stirring, 4 mL of tetraethylorthosilicate ("TEOS") in 2-propanol (10% v/v) was added, followed by another 3.5 mL of TEOS after 2 hours. The reaction was then continued for 18 hours. The α-Fe₂O₃/SiO₂ particles were harvested by centrifugation, and washed with ethanol and water several times before being vacuum-dried at room temperature. For hydrothermal SnO₂ deposition, 118 mg α-Fe₂O₃/SiO₂ particles were dispersed in 25 mL of ethanol/water (37.5 vol % ethanol) mixed solvent. To this suspension, urea (0.75 g) and potassium stannate trihydrate (113 mg; K₂SnO₃·3H₂O, Aldrich (St. Louis, Mo.), 99.9%) were added. After shaking by hand for about 5 minutes until the salts dissolved, the suspension was transferred to a 40 mL Teflon-lined stainless-steel autoclave, which was then heated in an air flow electric oven at 170° C. for 36 hours. After the autoclave was allowed to cool down naturally, the particles were washed with ethanol/water once before the same hydrothermal deposition was repeated. For synthesis of porous double-shelled nanococoons, about 34 mg α-Fe₂O₃/SiO₂ particles were used. After annealing the particles at 550-600° C. for 8 hours, the silica was dissolved in 1 M NaOH solution at 50° C. for about 2 days (alternately, the silica is dissolved by etching in a very diluted HF solution as SnO₂ tends to partially dissolve in NaOH solution when exposed to NaOH for extended periods of time).

[0063] The nanococoons were characterized with X-ray powder diffraction ("XRD") using a Scintag PAD X-ray Powder Diffractometer (Scintag PAD X, Cu Kα, λ=1.5406 Å)

(Scintag, Inc, Cupertino, Calif.), transmission electron microscopy (TEM/SAED) using a JEOL-1200EX transmission electron microscope (120 kV) (JEOL, Tokyo, Japan), ultra-high vacuum scanning transmission electron microscopy (UHV-STEM, 100 kV) (Fisons Instruments, Inc, San Carlos, Calif.) equipped with energy dispersive X-ray analysis (EDX), and field emission scanning electron microscopy (FE-SEM; LEO 1550) (Carl Zeiss, Oberkochen, Germany). Nitrogen adsorption and desorption isotherms were measured using the Micromeritics ASAP 2020 Accelerated Surface Area and Porosimetry analyzer (Micromeritics, Inc., Norcross, Ga.).

[0064] Numerous references, including patents and various publications, are cited and discussed in the description of this invention. The citation and discussion of such references is provided merely to clarify the description of the present invention and is not an admission that any reference is prior art to the invention described herein. All references cited and discussed in this specification are incorporated herein by reference in their entirety.

[0065] Variations, modifications and other implementations of what is described herein will occur to those of ordinary skill in the art without departing from the spirit and scope of the invention. While certain embodiments of the present invention have been shown and described, it will be obvious to those skilled in the art that changes and modifications may be made without departing from the spirit and scope of the invention. The matter set forth in the foregoing description and accompanying drawings is offered by way of illustration only and not as a limitation. The actual scope of the invention is intended to be defined in the following claims.

What is claimed is:

1. A nanostructure comprising at least one metal oxide nanostructured shell defining an inner void.

2. The nanostructure of claim 1 comprising at least two metal oxide nanostructured concentric shells, wherein the shells are not covalently linked to each other.

3. The nanostructure of claim 2, comprising two metal oxide nanostructured shell concentric shells, wherein the shells are not covalently linked to each other.

4. The nanostructure of claim 1 further comprising a solid core within the inner void.

5. The nanostructure of claim 4 wherein, the solid core comprises materials selected from the group consisting of Au, Ag, Pt and Pd.

6. The nanostructure of claim 5, wherein the solid core comprises materials with magnetic properties.

7. The nanostructures of claim 6, wherein the materials with magnetic properties comprise Fe, Co or Ni.

8. The nanostructures of claim 7, wherein the materials with magnetic properties comprise ferric oxides.

9. The nanostructures of claim 6, wherein the materials with magnetic properties are selected from the group consisting of ZnO, CuO, and Cu₂O.

10. The nanostructures of claim 6, wherein the materials with magnetic properties comprise metal sulfide semiconductors.

11. The nanostructures of claim 1, wherein at least one metal oxide nanostructured shell has one or more pores.

12. The nanostructures of claim 8, wherein the pore is an opening.

13. The nanostructure of claim 1, wherein the nanostructure is spherical, cylindrical or polyhedral.

14. The nanostructure of claim 1, wherein the nanostructure is bowl-shaped.

15. The nanostructure of claim 1, wherein the nanostructure is selected from the group consisting of nanoparticles, nanorods, nanobelts, nano-arrays, nanotubes, nanodisks, nanoboxes, nanospheres, nanocylinders, nanococoons, and nanospindles.

16. The nanostructure of claim 1, wherein the metal oxide comprises a metal selected from the group consisting of titanium, zirconium, aluminum, tin, germanium, indium, gallium, hafnium, vanadium, tantalum, zinc, copper, iron, cobalt, nickel, chromium, and manganese.

17. The nanostructure of claim 16, wherein the metal oxide is tin oxide.

18. The nanostructure of claim 1, wherein the nanostructure is polycrystalline.

19. The polycrystalline nanostructure of claim 18, wherein the average size of each crystal is between 1.0 and 50.0 nm.

20. The polycrystalline nanostructure of claim 19, wherein the average size of each crystal is between 10.0 and 20.0 nm.

21. The nanostructure of claim 1, wherein the maximum average cross-sectional distance of the nanostructure is between 50.0 and 1,000.0 nm.

22. The nanostructure of claim 21, wherein the maximum average cross-sectional distance of the nanostructure is between 100.0 and 500.0 nm.

23. The nanostructure of claim 22, wherein the maximum average cross-sectional distance of the nanostructure is between 75.0 and 150.0 nm.

24. The nanostructure of claim 1, wherein the thickness of the nanostructured shell defining the inner space is between 5.0 and 50.0 nm.

25. The nanostructure of claim 24, wherein the thickness of the nanostructured shell defining the inner space is between 10.0 and 40.0 nm.

26. The nanostructure of claim 25, wherein the thickness of the nanostructured shell defining the inner space is between 20.0 and 30.0 nm.

27. The nanostructure of claim 4, wherein the average diameter of the solid core within the inner space is between 5.0 and 500.0 nm.

28. The nanostructure of claim 27, wherein the average diameter of the solid core within the inner space is between 30.0 and 300.0 nm.

29. The nanostructure of claim 28, wherein the average diameter of the solid core within the inner space is between 50.0 and 150.0 nm.

30. The nanostructure of claim 11, wherein the average diameter of the pores in one or more of the nanostructured shells is between 1.0 and 100.0 nm.

31. The nanostructure of claim 30, wherein the average diameter of the pores in one or more of the nanostructured shells is between 3.0 and 30.0 nm.

32. The nanostructure of claim 1, wherein the nanostructure is rutile tetragonal SnO₂.

33. The nanostructure of claim 29, wherein the corresponding ring-like selected-area electron diffraction pattern of the nanostructure reveals diffraction rings from inside to outside which are indexed to (110), (101), (200), (211), and (112) planes of rutile SnO₂ respectively.

34. A process to produce the nanostructures of claim 1, comprising: mixing a metal oxide precursor with a solvent, and optionally one or more yield enhancing additives to form a mixture; and heating said mixture for at least about 3 hours.

35. The process of claim **34**, wherein the nanostructure is selected from the group consisting of nanoparticles, nanorods, nanobelts, nano-arrays, nanotubes, nanodisks, nanoboxes, nanospheres, nanocylinders, nanococoons, and nano spindles.

36. The process of claim **34**, wherein the metal oxide precursor is a precursor of metal oxides selected from the group consisting of titanium, zirconium, aluminum, tin, germanium, indium, gallium, hafnium, vanadium, tantalum, zinc, copper, iron, cobalt, nickel, chromium, and manganese.

37. The process of claim **36**, wherein the metal oxide precursor is a precursor of tin oxide.

38. The process of claim **37**, wherein the precursor is an alkali metal precursor salt.

39. The process of claim **38**, wherein the alkali metal is potassium or sodium.

40. The process of claim **39**, wherein the alkali metal is potassium.

41. The process of claim **34**, wherein the solvent is a polar solvent.

42. The process of claim **41**, wherein the polar solvent is an alcohol and water mixture.

43. The process of claim **42**, wherein the alcohol is any C_2 to C_{10} alcohol.

44. The process of claim **34**, wherein the solvent is a non-polar solvent seeded with a polar entity.

45. The process of claim **44**, wherein the polar entities are chosen from the group consisting of surfactants, polymers, charged oligomers and particulate materials.

46. The process of claim **34**, wherein the yield enhancing additives are selected from the group consisting of urea compounds and $-NH_2$ compounds.

47. The process of claim **46**, wherein the urea compounds are chosen from the group consisting of biuret, thiourea, thiobiuret, alkyl substituted ureas, aryl substituted ureas, alkyl substituted thioureas, aryl substituted thioureas, alkylene ether ureas, arylene ether ureas, alkylene ether thioureas and arylene ether thioureas.

48. The process of claim **34**, wherein the mixture is heated at a temperature of between about $140^\circ C.$ and about $200^\circ C.$ for between about 3 to about 24 hours.

49. The process of claim **48**, further comprising the step of cooling the nanostructure formed after heating.

50. The process of claim **49**, further comprising the step of washing the cooled nanostructure.

51. The process of claim **34**, wherein the nanostructure is formed by inside-out Ostwald ripening.

52. The process of claim **34**, wherein the nanostructure formed has enhanced electrochemical properties when used as an anode material in lithium ion batteries.

53. The process of claim **34**, wherein the nanostructure formed has initial discharge capacities between about 1000.0 mAh/g and 1,300.0 mAh/g.

54. The process of claim **34**, wherein the nanostructure formed can undergo at least about 25 discharge cycles while still functioning effectively at a discharge capacity of at least 300.0 mAh/g.

55. The process of claim **34**, wherein the nanostructure formed can undergo between 25 and 50 cycles while still functioning effectively at a discharge capacity of at least 300.0 mAh/g.

56. The nanostructure of claim **1**, further comprising a magnetic core.

57. The nanostructure of claim **56**, wherein the magnetic core comprises a ferric-based material.

58. The nanostructure of claim **57**, wherein the ferric based material is a ferric oxide.

59. The nanostructure of claim **58**, wherein the ferric oxide is Fe_3O_4 .

60. The nanostructure of claim **1**, further comprising a core having electrical properties.

61. The nanostructure of claim **1**, further comprising a core having semiconductor properties.

62. The nanostructure of claim **1**, further comprising a core bearing noble metals.

63. The nanostructure of claim **62**, wherein the noble metals are chosen from the group consisting of Au, Ag, Pt and Pd.

64. A process to manufacture the nanostructure of claim **60**, comprising: (a) coating a material capable of being magnetized with a silica-based material to form a particle in which said material is coated with the silica-based material; (b) coating the particle of step (a) with metal oxide such that the nanotemplate is surrounded by at least one metal oxide nanostructured shell; (c) heating the nanotemplate of step (b) at a temperature between 400 to $1000^\circ C.$ to cause annealing; (d) suspending said annealed structure of step (c) in a solvent suitable to dissolve the silica-based material.

65. The process of claim **64**, wherein the silica based material is amorphous silicon dioxide.

66. The process of claim **64**, wherein the material capable of being magnetized is $\alpha-Fe_2O_3$.

67. The process of claim **66**, wherein the process further comprises a step in which the $\alpha-Fe_2O_3$ is magnetized by H_2 reduction to Fe_3O_4 .

68. The nanostructure of claim **60**, further comprising an outermost shell comprising a semiconductor material.

69. The nanostructure of claim **68**, wherein the semiconductor material comprises carbon black.

70. The nanostructure of claim **68**, wherein the semiconductor material comprises a propylenevinylidene fluoride compound.

71. The nanostructure of claim **11**, wherein the pores are formed by treatment with a poregen material followed by heating at a temperature between $100^\circ C.$ to $1000^\circ C.$

72. The nanostructure of claim **11**, wherein the pores are formed by treatment with a poregen material followed by lyophilization at a temperature less than $0^\circ C.$

73. A process to produce the nanostructure of claim **1**, comprising: (a) hydrothermally depositing a metal oxide precursor on a template to form a nanostructure comprising a metal oxide nanostructured shell on said template; and (b) treating the nanostructure of step (a) with a solvent to dissolve the template material to create an internal void in said nanostructure.

74. A process to produce the nanostructure of claim **2**, comprising: (a) hydrothermally depositing a metal oxide precursor at least two times on a template to form a nanostructure comprising a plurality of metal oxide nanostructured shells on said template; and (b) treating the nanostructure of step (a) with a solvent to dissolve the template material to create an internal void in said nanostructure.

75. The process of claim **73**, wherein the metal oxide is SnO_2 .

76. The process of claim **73**, wherein the template is a silica-based compound.